

<b>Notice of References Cited</b>	Application/Control No. 10/602,467	Applicant(s)/Patent Under Reexamination SELVAMANICKAM ET AL.	
	Examiner Brian K Talbot	Art Unit 1762	Page 1 of 1

#### U.S. PATENT DOCUMENTS

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
	A	US-6,190,752	02-2001	Do et al.	428/141
	B	US-5,432,151	07-1995	Russo et al.	505/474
	C	US-6,214,772	04-2001	Iijima et al.	505/475
	D	US-5,650,378	07-1997	Iijima et al.	505/473
	E	US-6,797,313	09-2004	Fritzemeier et al.	427/62
	F	US-			
	G	US-			
	H	US-			
	I	US-			
	J	US-			
	K	US-			
	L	US-			
	M	US-			

#### FOREIGN PATENT DOCUMENTS

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Country	Name	Classification
	N	04-331,795	11-1992	Japan		
	O					
	P					
	Q					
	R					
	S					
	T					

#### NON-PATENT DOCUMENTS

*		Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)			
	U	In Plane Texturing Control of YBACUO Thin Films on Polycrystalline Substrates By Ion-Beam-Modified Intermediate Buffer Layers, Iijima et al., IEEE Vol. 3, No. 1, March 1993, pp. 1510-1515			
	V	Biaxially Aligned YSZ Buffer Layer on Polycrystalline Substrates, Iijima et al., International Symposium on Superconductivity, Oct. 14-17 1991, Tokyo Japan, pp. 1-4			
	W	Structural and Transport properties of Biaxially aligned YBACUO film on Polycrystalline Ni-based alloy with Ion Beam Modified buffer layers, Iijima et al., Journal of Applied Physics, vol. 73(3) August 1, 1993, pp. 1905-1911			
	X	In-plane aligned YBACUO thin films deposited on polycrystalline metallic substrates, Iijima et al., Applied Physics Letters, Vol. 60(6) February 10, 1992, pp. 769-771			

\*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)  
Dates in MM-YYYY format are publication dates. Classifications may be US or foreign.